

Temperature dependence of spin-orbit torques in W/CoFeB bilayers

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We report on the temperature and layer thickness variation of spin-orbit torques in perpendicularly magnetized W/CoFeB bilayers. Harmonic Hall voltage measurements reveal dissimilar temperature evolutions of longitudinal and transverse effective magnetic field components. The transverse effective field changes sign at 250 K for a 2 nm thick W buffer layer, indicating a much stronger contribution from interface spin-orbit interactions compared to, for example, Ta. Transmission electron microscopy measurements reveal that considerable interface mixing between W and CoFeB is primarily responsible for this effect.

Efficient manipulation of magnetization using electrical signals at the nanoscale will further the development of next generation magnetic memories, logic¹ and microwave devices². The spin Hall effect³ and Rashba effect⁴ are intensively studied, as they produce effective magnetic fields that can be used to switch the magnetization of magnetic nano-pillars⁵, excite microwave oscillations in nano-discs⁶ or induce magnetic domain-wall motion in nanowires⁷. Quantitatively, spin-orbit torques are characterized by the spin Hall angle (θ_H), which is a measure of the ratio between spin current density (J_s) and charge current density (J_c). Different heavy metal/ferromagnet bilayers have been proposed as the source of spin-orbit torque, including: Ta⁸, Hf⁹, Pt¹⁰, CuIr¹¹, and W^{12,13}, with W exhibiting the largest θ_H to date. Recent work on oxidized W has also revealed promising results¹⁴. Studies on symmetry of spin-orbit torques pointed out different contributions to the effective magnetic field arising from the bulk spin Hall effect and interface Rashba interactions¹⁵. In addition, it has been shown that the interface between heavy metal and ferromagnetic layers strongly affects both θ_H ¹⁶ and the spin diffusion length¹⁷.

In this letter, we demonstrate that spin-orbit torques in W/CoFeB bilayers are strongly affected by interface mixing. Both transverse and longitudinal torque components are measured in a temperature range from 19 to 300 K. The interface contribution to the transverse effective field is dominant at low temperatures, leading to a sign reversal at 250 K, where the bulk spin-orbit torque starts to dominate. Considerable mixing between W and CoFeB is supported by transmission electron microscopy (TEM) and X-ray reflectivity (XRR) analysis.

The investigated samples consisted of sputter-deposited multilayers with the following structure: W(t_W)/Co₁₂Fe₆₈B₂₀(1.3)/MgO(2.5)/Ta(4) (thicknesses in nm), with $t_W = 2, 4,$ and 6 nm. After deposition, the samples were measured using vibrating sample magnetometry (VSM), X-ray diffraction (XRD) and XRR and they were successively annealed in a high vacuum

chamber. Microstructure analysis was performed using a JEOL 2200FS TEM with double Cs correctors, operated at 200 keV. Cross-sectional TEM specimens were prepared by a MultiPrep polishing machine (Allied High-Tech) and Ar ion milling. Selected samples were patterned using e-beam lithography, ion-beam etching and lift-off processes into 70 μm long Hall bars of different width spanning from 1 to 40 μm . During microfabrication, electrical contacts with a dimensions of 100 \times 100 μm were deposited and most of the Ta top layer was etched away leaving only a thin oxidized layer as protection.

The resistivity of the samples was measured using a four-probe method, both for as-deposited devices (with in-plane magnetic anisotropy) and annealed ones (with effective perpendicular magnetic anisotropy - PMA). The harmonic Hall voltage measurements were carried out using lock-in amplification in a Janis cryogenic probe station equipped with an electromagnet. During these experiments, the temperature was varied between 19 and 300 K. Measurements were performed for various magnetic field orientations: perpendicular to the sample plane (along z axis - i.e. anomalous Hall effect (AHE) configuration), longitudinal to the stripe (along x axis) and transverse to the stripe (along y axis).

First, the crystallographic phases of W with different layer thicknesses ($t_W = 2, 4,$ and 6 nm) were determined using XRD measurements. The θ - 2θ scans of Fig. 1(a) reveal that the β -tungsten phase is present in all samples, whereas, a clear α -tungsten reflection is visible only for the sample with a 6 nm thick W layer. The same conclusion can be drawn from four-point resistivity measurements. Assuming a CoFeB resistivity of 113 $\mu\Omega\cdot\text{cm}$ (measured independently) and a parallel resistor model, the calculated W resistivity (ρ_W) amounts 128 and 105 $\mu\Omega\cdot\text{cm}$ for $t_W = 2$ nm and 4 nm, respectively, but it decreases significantly to 36 $\mu\Omega\cdot\text{cm}$ for $t_W = 6$ nm, supporting the presence of a low-resistive α -tungsten phase¹⁸. We also verified, that α -tungsten does not form in the thinner W layers during annealing (Fig. 1(b)). Be-

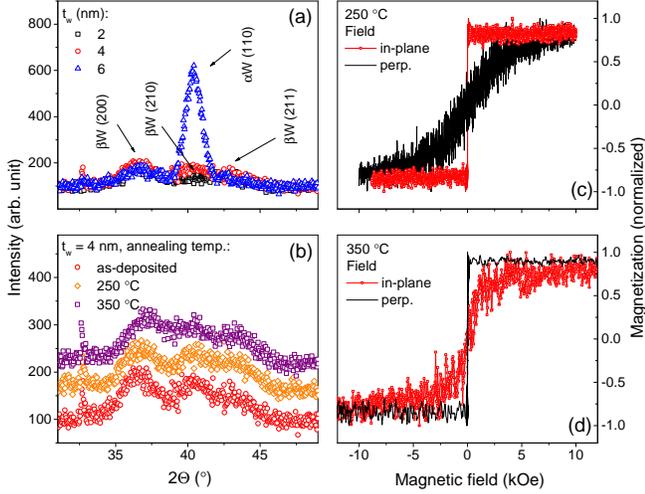


FIG. 1: XRD θ - 2θ scans for as-deposited samples with different t_W (a) and for annealed samples with $t_W = 4$ nm (b) – curves are offset for clarity. In-plane and perpendicular magnetization curves for the sample with $t_W = 4$ nm after annealing at 250 °C (c) and 350 °C (d).

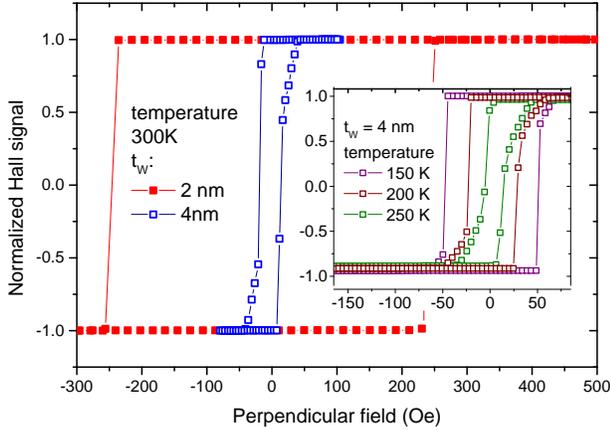


FIG. 2: AHE vs. perpendicular magnetic field measured in a room temperature for samples with $t_W = 2$ (full symbols) and 4 nm (open symbols). Inset presents AHE measured for $t_W = 4$ nm measured at various temperatures.

cause the β -tungsten phase is crucial for obtaining PMA and large spin Hall angles¹⁹, we focus on the thinner W buffers only. We note that the resistivity of W/CoFeB bilayers did not change (within experimental error) upon annealing.

Independently, the magnetic properties of the deposited stacks were verified using VSM. Exemplary magnetic hysteresis loops for $t_W = 4$ nm are presented in Fig. 1. The measurements indicate a transition from in-plane anisotropy to PMA after annealing at 350 °C, which is consistent with our earlier work²⁰.

Next, the AHE of samples with $t_W = 2$ and 4 nm were measured in perpendicular magnetic field (Fig. 2).

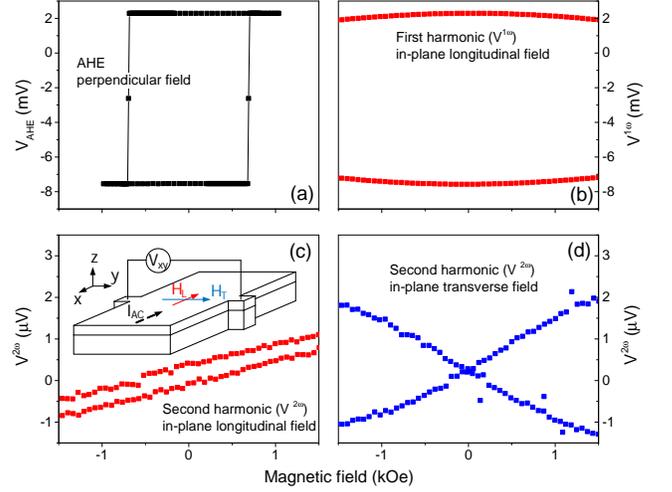


FIG. 3: (a) AHE vs. perpendicular magnetic field, (b) first harmonic Hall voltage vs. longitudinal in-plane field, (c) and (d) second harmonic Hall voltage vs. longitudinal and transverse field, respectively, obtained at $T = 19$ K for $t_W = 2$ nm. Note that the first Harmonic Hall voltage signal vs. transverse field is similar to (b). Inset in (c) shows the harmonic Hall voltage measurement configuration.

Although both W layers induce PMA in CoFeB, the switching for $t_W = 2$ nm is more abrupt compared to $t_W = 4$ nm. This effect, which can be attributed to more gradual magnetization rotation or magnetic domain formations²¹, hampers the extraction of effective magnetic fields. We note that this behavior persists even at low temperatures (inset in Fig. 2), ruling out superparamagnetism in 1.3 nm thick CoFeB as its origin. Because of abrupt magnetic switching, we limit our discussion to effective magnetic fields in W/CoFeB bilayers with $t_W = 2$ nm.

Figure 3 shows AHE and harmonic Hall voltages at $T = 19$ K for the sample with $t_W = 2$ nm. The first harmonic Hall voltage signal measured in a magnetic field applied longitudinal to the Hall bar (H_L) exhibits a parabolic shape and was fitted using a quadratic function both for the remanent magnetization point along $+z$ and $-z$ directions. Results for a magnetic field applied transverse to the long axis of the hall bar (H_T) are almost identical. Likewise, the second harmonic signal was fitted using a linear function for both remanent magnetic field orientations. In this case, the two fitted lines are either symmetric (measurement along H_L - Fig. 3(c)) or asymmetric (measurement along H_T - Fig. 3(d)) with respect to the magnetic field polarity. The model presented in Ref.²² was used to calculate the effective longitudinal ΔH_L and transverse ΔH_T magnetic fields:

$$\Delta H_{L(T)} = -2 \frac{\partial V^{2\omega}}{\partial H_{L(T)}} / \frac{\partial^2 V^{1\omega}}{\partial H_{L(T)}^2} \quad (1)$$

Using a parallel resistor model, we calculated the cur-

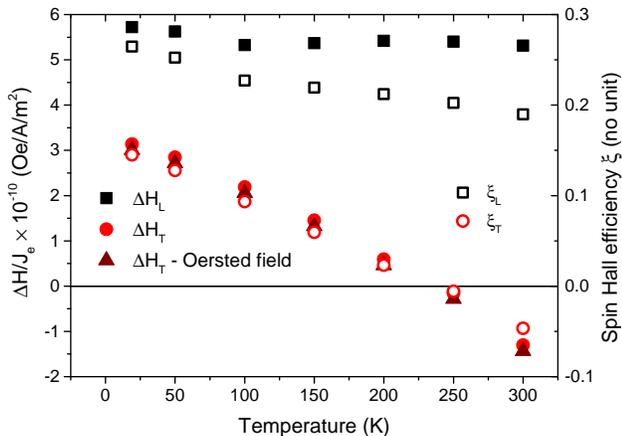


FIG. 4: Effective longitudinal ΔH_L and transverse ΔH_T fields as a function of temperature - left axis, measured for a 10- μm -wide stripe with $t_W = 2$ nm. The Oersted field contribution was calculated from the current flowing through the buffer and subtracted from the transverse field. The right axis presents data of spin Hall efficiency calculated using Eq. 2.

rent density in the W buffer layer as $J_c = 2.17 \times 10^{10}$ A/m². J_c drops by about 3% at $T = 19$ K with respect to the room temperature value, as the resistance increases with decreasing temperature. This negative temperature coefficient is explained by the existence of an amorphous phase in the W buffer and will be discussed in detailed elsewhere. The data presented here were measured in 10- μm -wide stripe, however, no significant dependence of the strip's width on the determined values of effective magnetic field were found. Instead of θ_H , we characterized our bilayers using damping-like and field-like spin-orbit torque efficiencies (ξ_L and ξ_T , respectively), as we independently measured these two torque components. The following equation was used to calculate the effective spin-orbit torques:

$$\Delta H_{L(T)}/J_e^W = \hbar \xi_{L(T)}/2eM_s t'_{\text{CoFeB}} \quad (2)$$

Where \hbar is the reduced Planck's constant, e is the electron charge, M_s is the saturation magnetization and t'_{CoFeB} is the effective thickness of CoFeB: $t'_{\text{CoFeB}} = 0.92$ nm (comparing to $t_{\text{CoFeB}} = 1.3$ nm nominal thickness, without a magnetic dead layer taken into account)²⁰. The saturation magnetization of CoFeB at room temperature equals $\mu_0 M_s = 1.6$ T and it increases to 2 T at $T = 19$ K. Figure 4 presents the effective magnetic fields and spin-orbit torque efficiencies vs. temperature.

We note that a relatively large planar Hall effect (PHE) of maximum 30% of AHE value²³ was measured in this sample. However, its magnitude vanishes when the magnetic field is aligned along the x or y directions, and therefore, we did not take it into account in the analysis of the effective magnetic fields.

The result of ξ_L are in agreement with spin Hall angles derived in the literature data for W buffer layers^{12,13,19}.

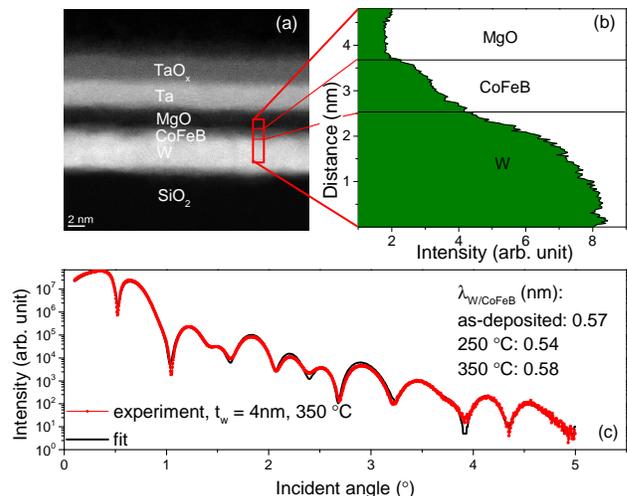


FIG. 5: Z-contrast image of fabricated multilayer stack (a) and line scan profile along vertical axis (b), indicating chemical intermixing at the interface between CoFeB and W. Good fits to XRR measurement are only obtained if large W/CoFeB interface roughness $\lambda_{W/\text{CoFeB}}$ is assumed (c). The interface roughness does not change during annealing.

A slightly higher value is expected for thicker W, as $t_W = 2$ nm used here is smaller than the spin diffusion length of W¹⁹. The temperature dependence of the longitudinal spin-orbit-torque is similar to Ta²⁴. On the other hand, the transverse effective field changes sign at around 250 K, which is not the case for Ta with the same thickness. Similar behavior has only been measured for very thin Ta, namely $t_{\text{Ta}} = 0.5$ nm, which indicates a much stronger interface effect in W. Generally, interface interactions (for example the Rashba effect) are dominant for thin buffers, whereas, for thicker heavy metals stronger contributions from field-like spin torques originating in the bulk are expected. Therefore, we conclude that in our case ($t_W = 2$ nm), both effects are of similar magnitude. This also implies, that the field-like spin-orbit torque opposes the interfacial interactions and that it varies more strongly with temperature.

To elucidate the origin of the strong interface effect, TEM analysis of the samples was performed. Figure 5 presents a Z-contrast image. The chemical sensitivity of the high-angle scattered electron signal provides good contrast between the polycrystalline W buffer, CoFeB/MgO bilayer and the Ta film with a thin oxidized layer on top. The line scan in Fig. 5(b) shows a gradual change of Z-contrast near the W/CoFeB interface, providing proof of considerable intermixing between these two layers. This observation is further corroborated by the XRR measurements of Fig. 5(c), which show that the W/CoFeB interface is very rough ($\lambda_{W/\text{CoFeB}} = 0.57$ nm), whereas a much smaller roughness is obtained for the CoFeB/MgO interface ($\lambda_{\text{CoFeB}/\text{MgO}} = 0.18$ nm). We note that $\lambda_{W/\text{CoFeB}}$ is not affected by thermal annealing of the sample, i.e., intermixing primarily occurs during

film growth.

Strong intermixing between the W and CoFeB layers, explains the large interface contribution (for example via the Rashba effect), to the total spin-orbit effective magnetic field in this study. Moreover, it can also explain high spin-orbit interactions in W/CoFeB bilayer leading to strong planar and spin Hall effects as well as anisotropic and spin-Hall magnetoresistance¹³.

In summary, we investigated spin-orbit torques in perpendicularly magnetized CoFeB on thin W buffer layers. Harmonic Hall voltage measurements were used to determine longitudinal and transverse spin-orbit effective magnetic fields. The damping-like spin-orbit torque component is found to slightly increase with decreasing temperature reaching $\xi_L = 0.27$ at 19 K. In contrast, the field-like component, depends strongly on temperature and changes sign at 250 K. This temperature dependence indicates a strong interface contribution to the total spin-orbit torque (Rashba effect). From TEM and XRR measurements, we conclude that the large interface effect originates from strong intermixing between the W

and CoFeB layers.

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